

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Patent Application of	(16 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6 6
Kazuya KAMON	Group Art Unit: 1756
Application No.: 09/320,946	Examiner: S. Mohamedulla
Filed: May 26, 1999	Confirmation: 5658
For: PHOTOMASK, FABRICATION METHOD OF PHOTOMASK, AND FABRICATION METHOD OF SEMICONDUCTOR INTEGRATED CIRCUIT))))
PETITION FOR EXTENSION OF TIME	
Assistant Commissioner for Patents Washington, D.C. 20231	
Sir:	
The following extension of time is requested to <u>respond to Office Action dated January 3.</u>	
<u>2002</u> :	
second month to <u>June 3, 2002</u> ; the extension fee is:	
[] \$145.00 [X] \$290.	
[X] A first month extension fee in the amount of \$ 110.00 was paid on May 3, 2002.	
[] Charge \$to Deposit Account No. 02-4800.	
The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R.	
§§ 1.16, 1.17 and 1.21 that may be required by this	paper, and to credit any overpayment, to
Deposit Account No. 02-4800. This paper is submitted in duplicate.	
Res	pectfully submitted,
Вия	RNS, DOANE SWECKER & MATHIS, L.L.P.
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(703) 836-6620 Date: June 3, 2002

06/04/2002 02 FC:116

7C 1700 (10/01)